

SERIAL NO. 10/050,360

GROUP: 2184

EXAM. INITIALS	REF. DES.	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE APPROPRIAT
<i>MS</i>	A1	6,088,222	7/11/00	Schmitt et al.	<i>361</i>	<i>686</i>	<b>COPY OF PAPER ORIGINALLY FILED</b>
<i>MS</i>	A2	6,067,225	5/23/00	Reznikov et al.	<i>361</i>	<i>685</i>	
<i>MS</i>	A3	6,061,232	5/9/00	Ho	<i>361</i>	<i>685</i>	
<i>MS</i>	A4	5,572,402	11/5/96	Jeong	<i>361</i>	<i>685</i>	
<div> <div>RECEIVED</div> <div>AUG 26 2002</div> <div>Technology Center 2100</div> </div> <div> <div>RECEIVED</div> <div>OCT 04 2002</div> <div>Technology Center 2100</div> </div>							

EXAM. INITIALS	REF. DES.	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATIO YES/NO
<i>MB</i>	A5	0 713 219	11/15/95	EP			

<i>mm</i>	A6	International Search Report application no. GB0101213.7, mailed 5/7/02.

DATE CONSIDERED: 4/16/03

Information Disclosure Statement--PTO 1449 (modified)

Form PTO-1449 (modified)

## List of Patents and Publications For Applicant's Information

## Disclosure Statement

(Use several sheets if necessary)

ATTY. DKT. NO. 5681-09000

APPLICANT: Gough, et al

**FILING DATE:** January 16, 2002




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## U.S. PATENT DOCUMENTS

EXAM. INITIALS	REF. DES.	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE APPROPRIAT
MM	B1	5,226,828	7/13/93	Fietz	439	1600	
					RECEIVED SEP 13 2002 Technology Center 2100		
					RECEIVED OCT 04 2002 Technology Center 2100		

## FOREIGN PATENT DOCUMENTS

EXAM. INITIALS	REF. DES.	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATIO YES/NO
	B2	11348675	12/21/99	JP			
	B3	07220464	8/18/95	JP			
							

**OTHER ART** (Including Author, Title, Date, Pertinent Pages, Etc.)

	B4	International Search Report, application no. PCT/GB 02/0056, international filing date 08/01/02

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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the patent owner.